

<b>Notice of References Cited</b>	Application/Control No. 10/092,685	Applicant(s)/Patent Under Reexamination LIN, SHIN CHAI MARK	
	Examiner Phylesha L. Dabney	Art Unit 2614	Page 1 of 1

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	L	US-			
	M	US-			

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**NON-PATENT DOCUMENTS**

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